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(12) **United States Design Patent**
Rydlewicz

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(54) **DIAMOND**

(71) Applicant: **WORLD TREND ENTERPRISES LIMITED**, Hong Kong (HK)

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(73) Assignee: **World Trend Enterprises Limited**, Hong Kong (HK)

(**) Term: **15 Years**

(21) Appl. No.: **29/630,355**

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(30) **Foreign Application Priority Data**

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(51) **LOC (11) Cl.** **11-01**

(52) **U.S. Cl.**
USPC **D11/90**

(58) **Field of Classification Search**
USPC D11/1-2, 26-29, 89-92; 63/26-28, 32
CPC A44C 17/00; A44C 17/01; A44C 17/005;
A44C 17/007; A44C 17/008

See application file for complete search history.

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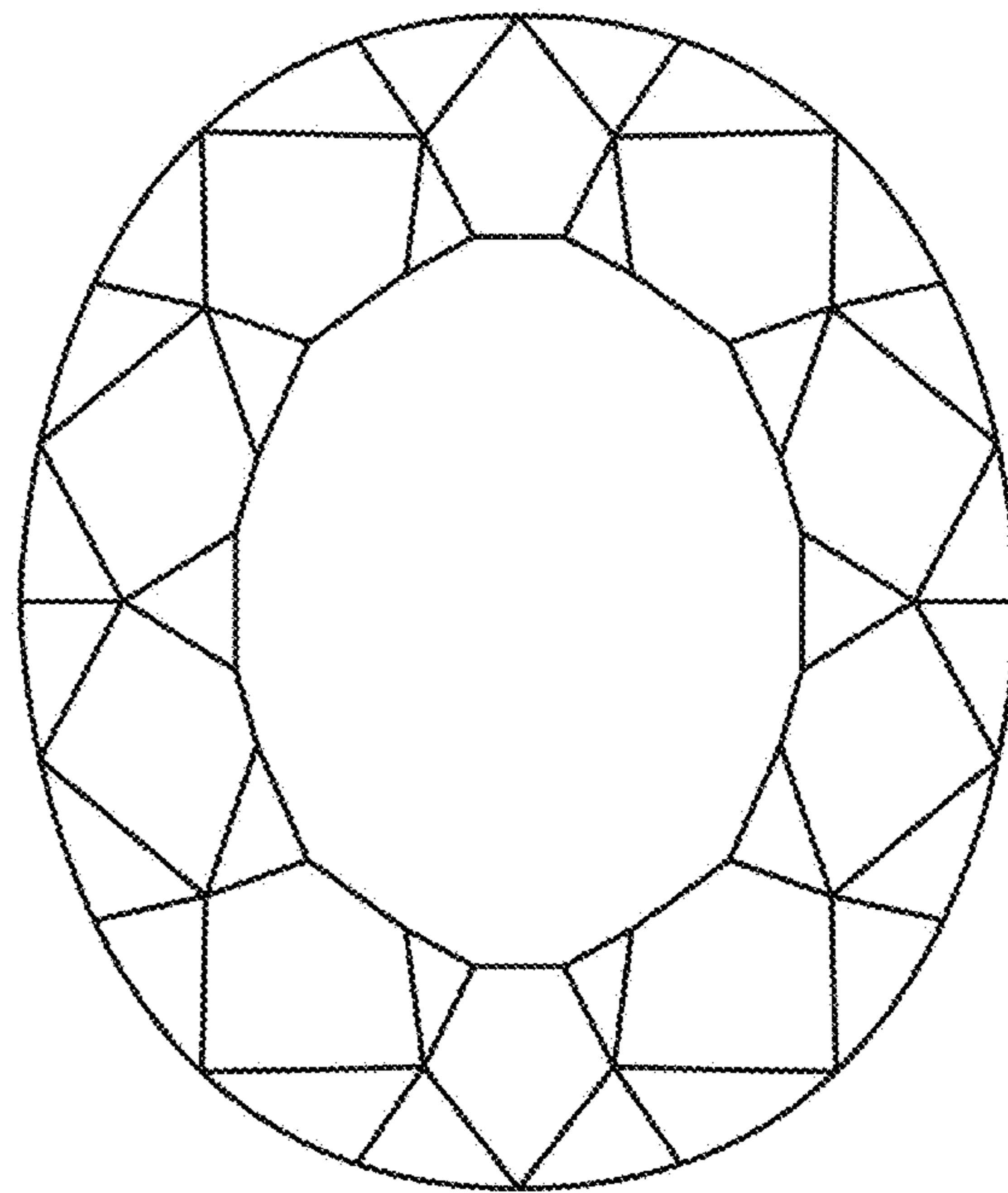
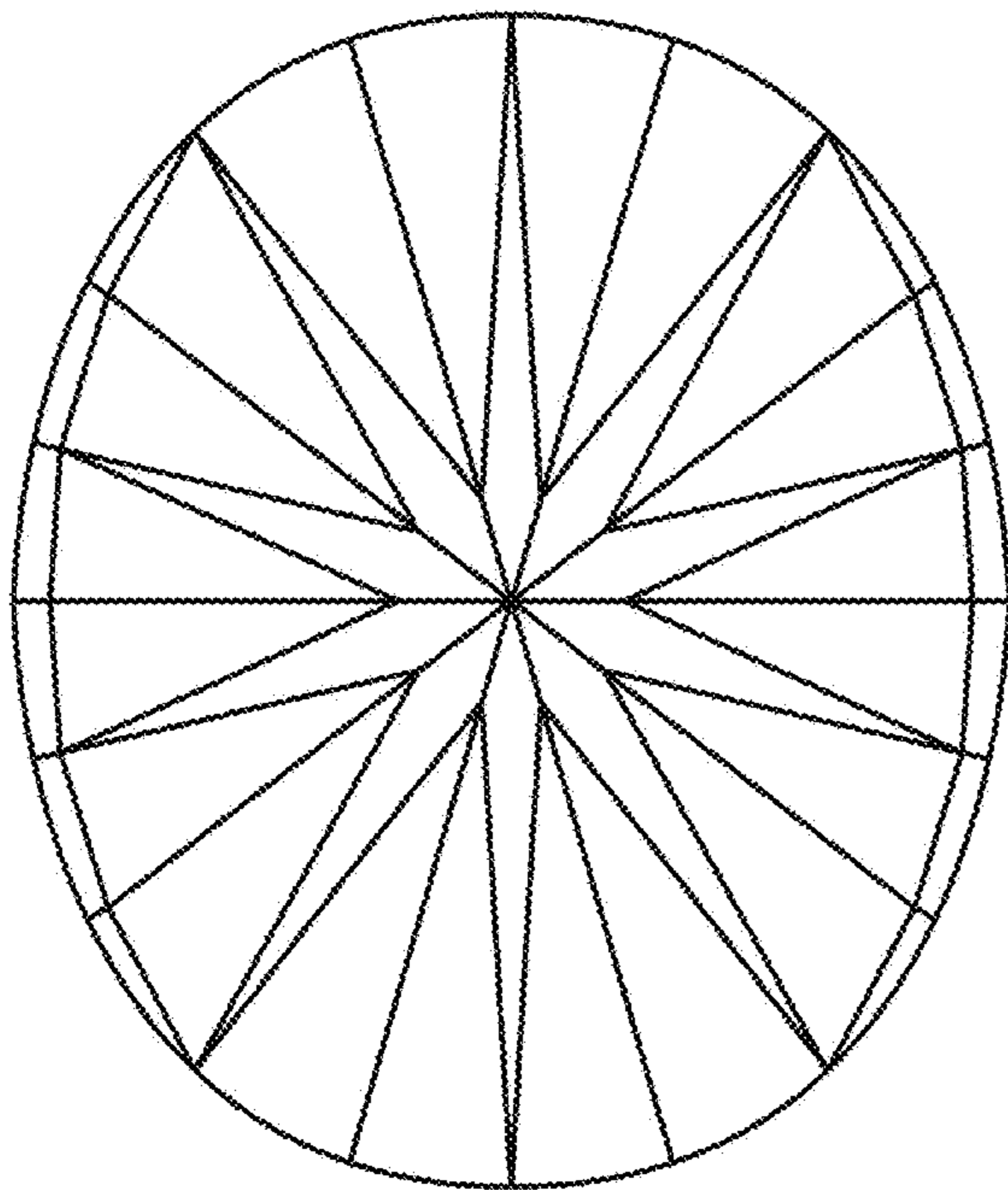
(57) **CLAIM**

The ornamental design for a diamond, as shown and described.

DESCRIPTION

FIG. 1 is a bottom plan view of the claimed design;
FIG. 2 is a top plan view thereof;
FIG. 3 is a side elevational view, the opposite side elevation view being identical; and,
FIG. 4 is another side elevational view, the opposite side elevational view being identical.

1 Claim, 3 Drawing Sheets



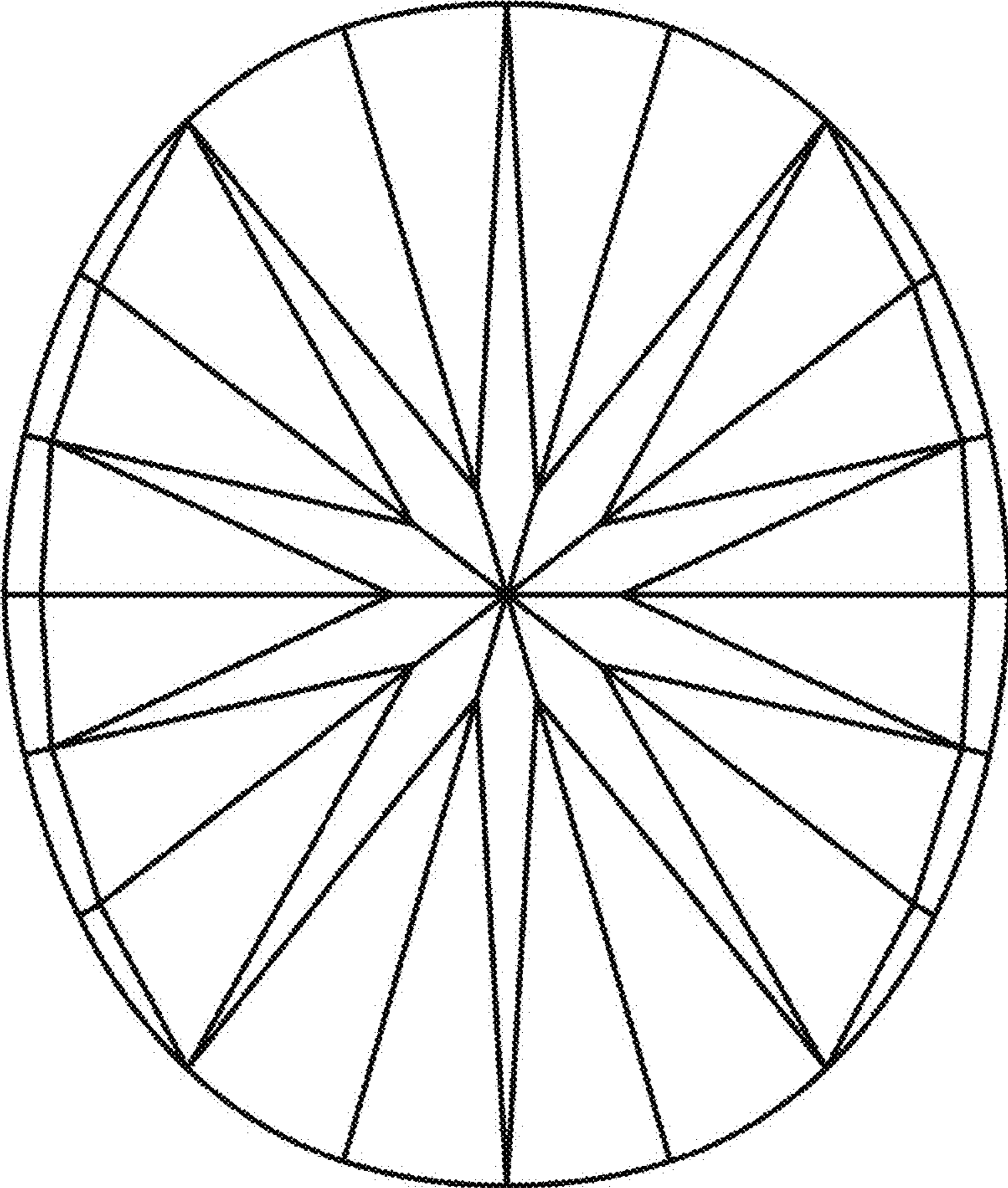


FIG. 1

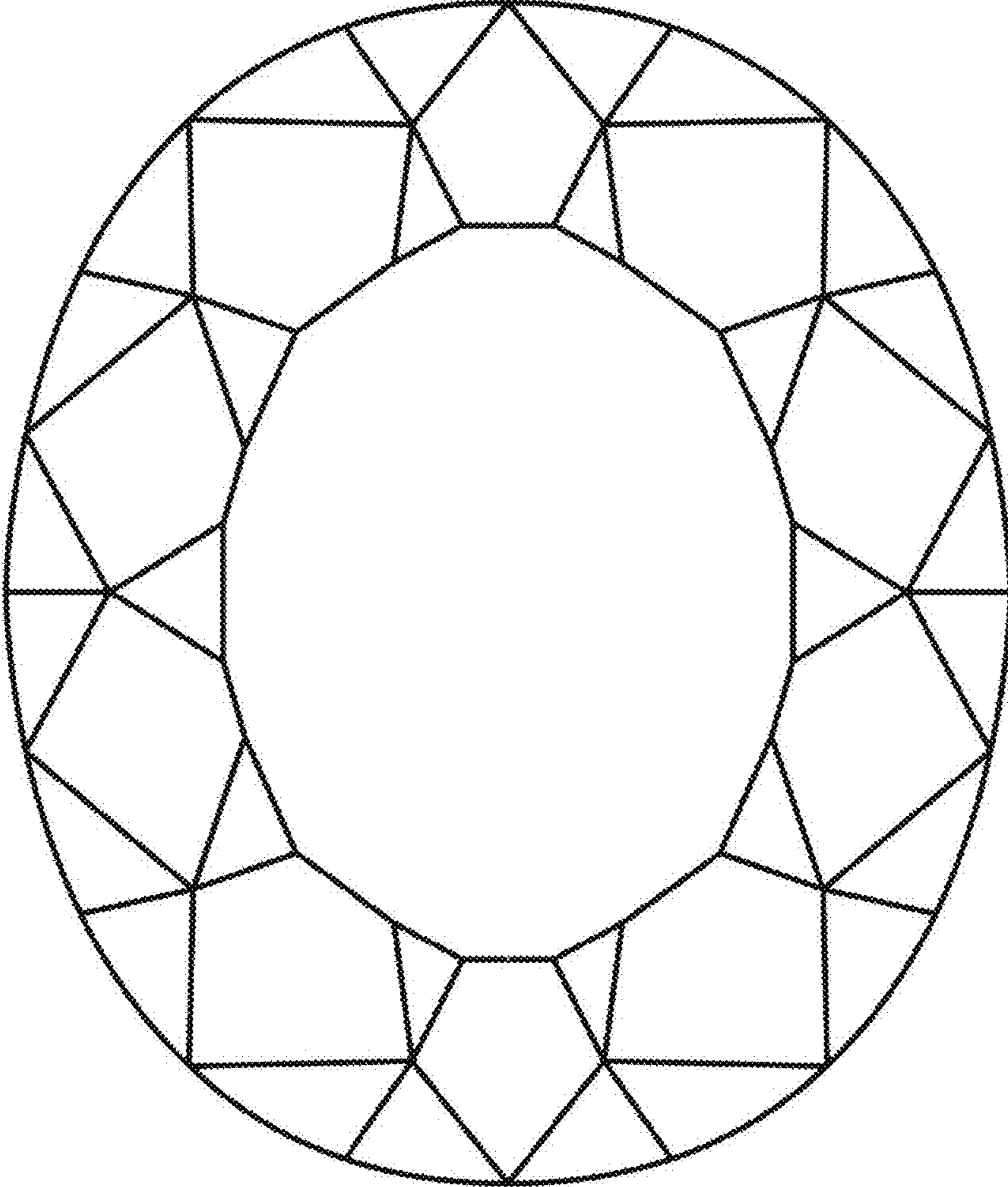


FIG. 2

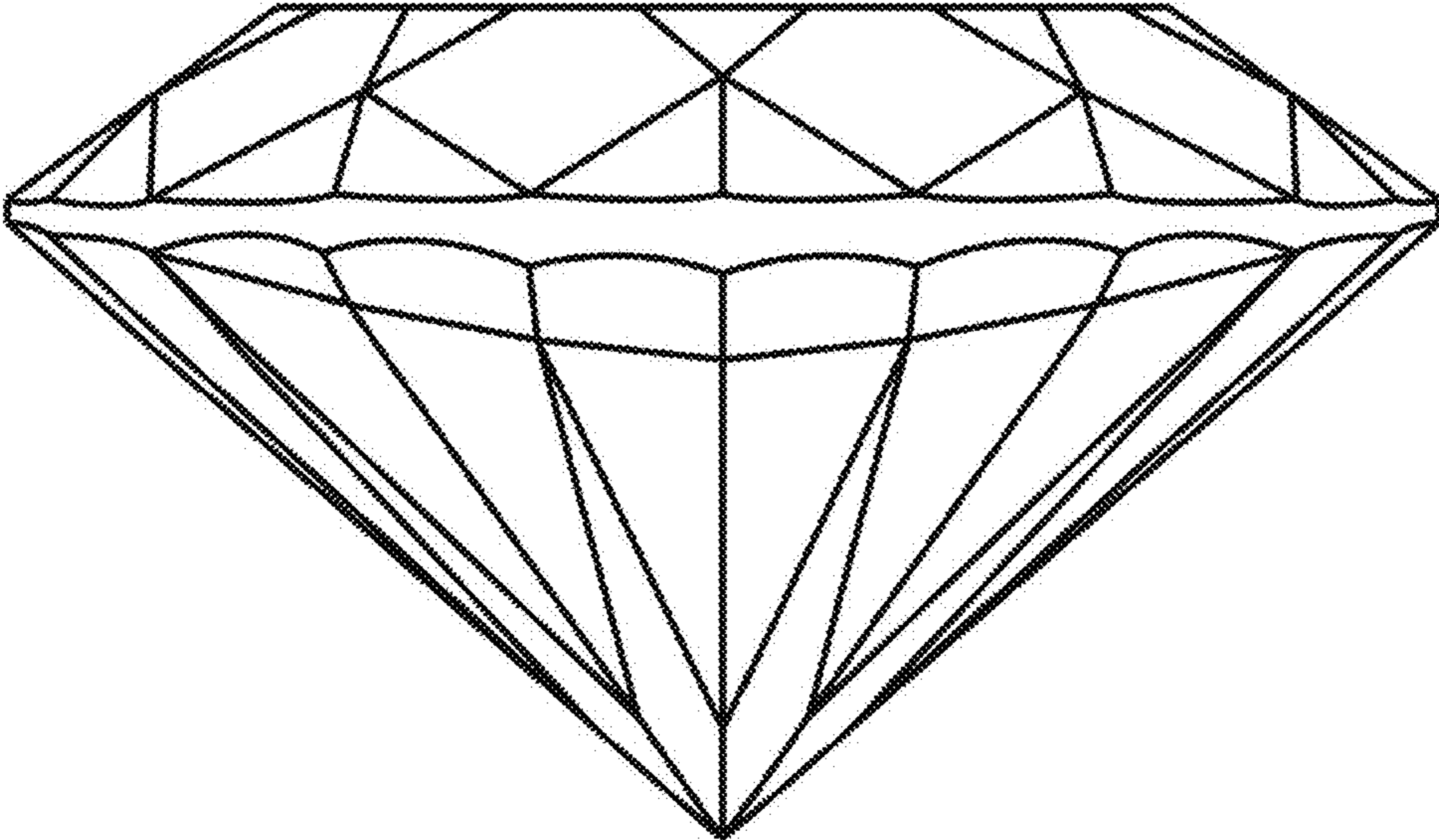


FIG. 3

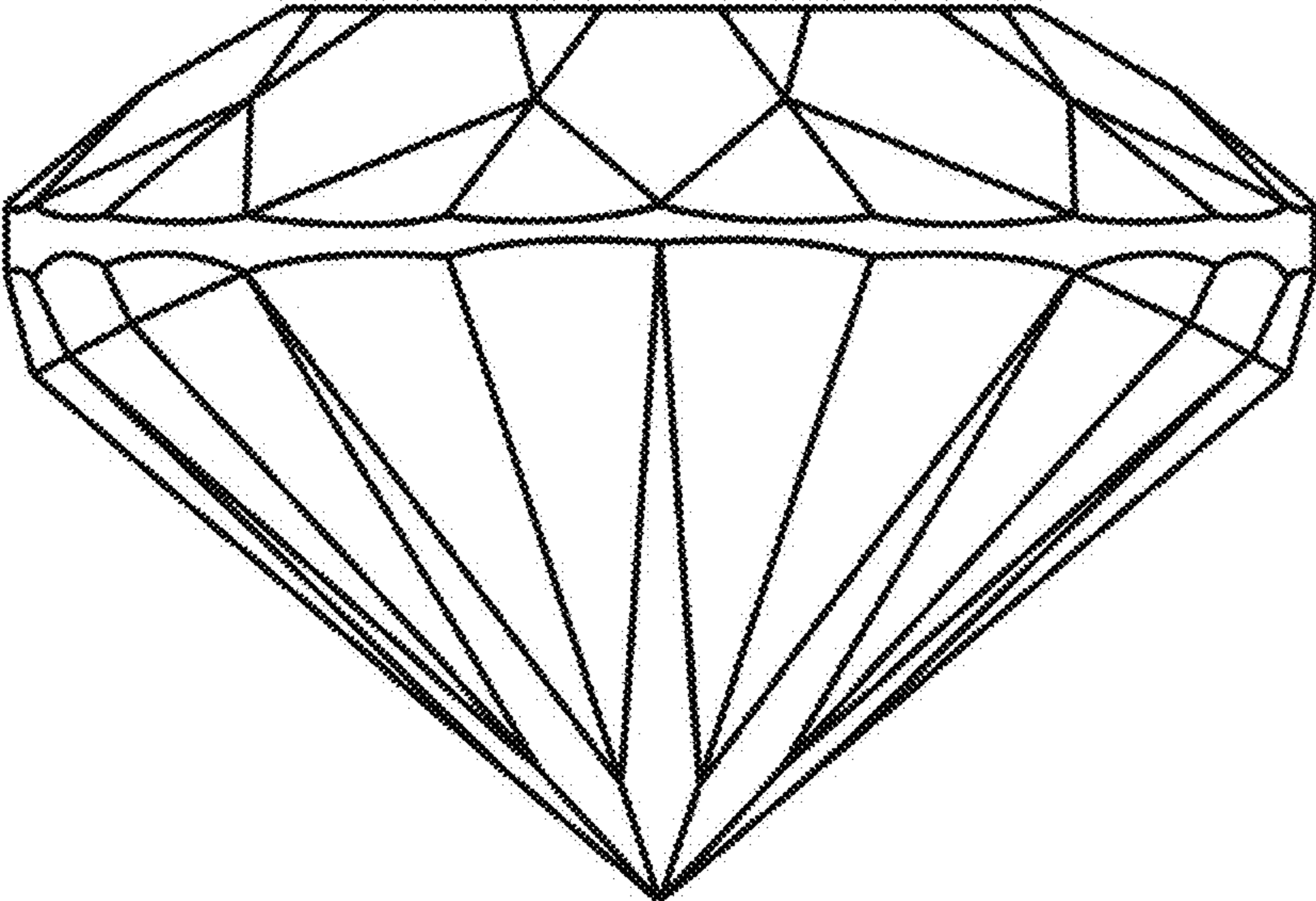


FIG. 4